

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application Serial No. ....10/757,276  
Filing Date .....January 14, 2004  
Inventor.....Kevin Beaman, et al.  
Assignee.....Micron Technology, Inc.  
Group Art Unit.....2813  
Examiner .....Stephen Smoot  
Attorney's Docket No. ....MI22-2475  
Customer No.....021567  
Title: A Method of Forming a Structure over Semiconductor Substrate

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Reference - - See attached Form PTO-1449

The attached Form PTO-1449 is submitted in compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the references listed on the attached Form PTO-1449. Pursuant to Federal Register Vol. 69, No. 182, pg. 56542 (September 21, 2004), no copies of any cited U.S. patents or U.S. published applications are included herewith. Copies of all other cited art references, if any, are attached. No admission is made regarding whether the submitted references are prior art.

Citation of this reference is respectfully requested.

Respectfully submitted,

Date: \_\_\_\_\_

9-18-07



\_\_\_\_\_  
D. Brent Kenady  
Reg. No. 40,045  
Customer No. 021567

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY. DOCKET NO. MI22-2475		SERIAL NO. 10/757,276	
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)					APPLICANT Kevin L. Beaman			
					FILING DATE January 14, 2004		GROUP 2813	
U.S. PATENT DOCUMENTS								
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA							
	AB							
	AC							
	AD							
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	AI							
	AJ							
	AK							
	AE							
	AM							
	AN							
	AO							
	AP							
	AQ							
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
	AR	Millman, Microelectronics, 1979, p. 91-92						
	AS							
EXAMINER					DATE CONSIDERED			
<p>*EXAMINER. Initial if reference is considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>								